## **Supporting Information**

## Interfacing boron monophosphide with molybdenum disulphide for an ultrahigh performance in thermoelectrics, 2D excitonic solar cells and nanopiezotronics

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The piezoelectric stress coefficient/tensor,  $e_{ij}$ , which relates the polarization  $P_i$  to the applied strain  $\varepsilon_j$  is given by  $P_i = \sum_j e_{ij}\varepsilon_j$  can be directly obtained from first-principle calculations. Instead of the piezoelectric stress tensor  $(e_{ij})$ , piezoelectric strain tensor  $d_{ij}$  is of greater importance in ultrathin 2D materials. It relates the induced polarization to the applied stress,  $P_i = \sum_j d_{ij}\sigma_j$  (I) and is more straight forward in ultra-thin circuit designs.<sup>1</sup> Linear piezoelectric coefficients  $e_{ijk}$  and  $d_{ijk}$  are the third rank tensors that couple electronic polarization  $(P_i)$  or the macroscopic electric field  $(E_i)$  to the second-rank stress tensor  $(\sigma_{jk})$  or the strain tensor  $(\varepsilon_{jk})$  as given by:

$$d_{ijk} = \left(\frac{\partial P_i}{\partial \sigma_{jk}}\right)_{E,T} = \left(\frac{\partial \varepsilon_{ij}}{\partial E_k}\right)_{\sigma,T}$$
(II)  
$$e_{ijk} = \left(\frac{\partial P_i}{\partial \varepsilon_{jk}}\right)_{E,T} = -\left(\frac{\partial \sigma_{jk}}{\partial E_i}\right)_{\varepsilon,T}$$
(III)

where  $i, j, k \in \{1, 2, 3\}$  corresponds to x, y, z direction respectively.

Further piezoelectric coefficients are defined as

$$e_{ijk} = \frac{\partial P_i}{\partial \varepsilon_{jk}} = e_{ijk}^{elc} + e_{ijk}^{ion} \quad (IV)$$
$$d_{ijk} = \frac{\partial P_i}{\partial \sigma_{jk}} = d_{ijk}^{elc} + d_{ijk}^{ion} \quad (V)$$

In contrast, the relaxed-ion piezoelectric tensors  $e_{ijk}(d_{ijk})$  are obtained from the sum of ionic and electronic contributions with the fully relaxed ionic positions. The relaxed-ion coefficients would be more reliable because they are experimentally relevant. The symmetry of the material reduces when we thinned down to monolayers. Hence, the stress/strain tensor of rank three reduces to rank two. Combining the relation between piezoelectric stress and strain coefficients,  $e_{ik}$  and  $d_{ij}$  and elastic stiffness coefficients  $C_{jk}$  for 2D material:  $e_{ik} = d_{ij}C_{jk}$  where i = 1, 2, 3 represents x, y, zdirection and for j, k we have used Voigt notation<sup>2</sup>; 1 = xx, 2 = yy, 3 = zz, 4 = yz, 5 = zx, 6 = xy.

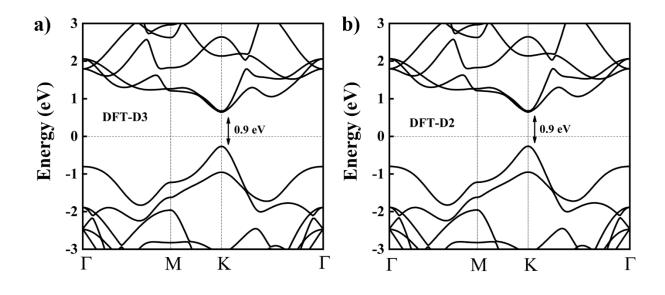


Figure S1: Calculated electronic dispersion of MoS<sub>2</sub>/BP using GGA-PBE with (a) DFT-D3 and (b) DFT-D2.

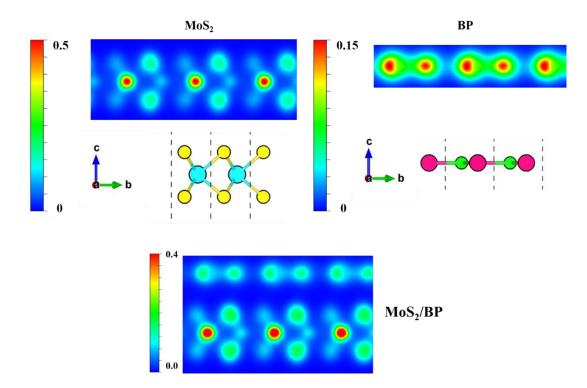


Figure S2: Charge density contour maps  $(e/Å^3)$  for pristine monolayer MoS<sub>2</sub>, BP and their heterobilayer.

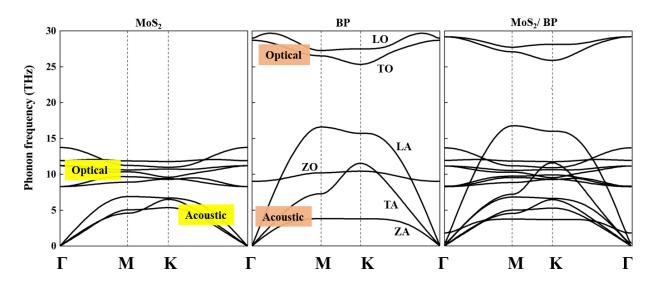


Figure S3: Phonon dispersion of individual and heterobilayer

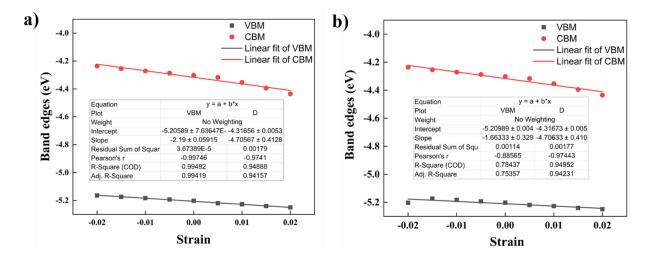


Figure S4: (a) CBM and VBM as a function of uniaxial compression or tension of MoS<sub>2</sub>/BP along K-Γ direction, (b) K-M direction.

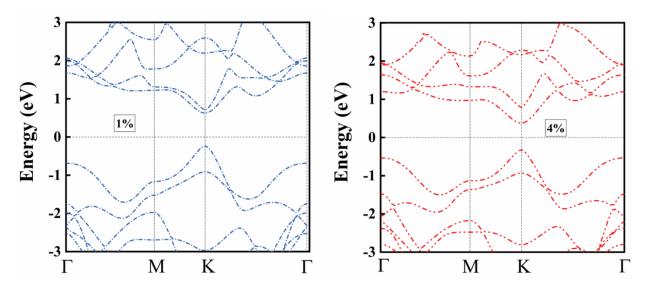


Figure S5: Evolution in the electronic band dispersion in the MoS<sub>2</sub>/BP heterobilayer with the application of biaxial tensile strain based on GGA-PBE. The bands arising from the individual monolayers are shown in Fig. 2(c). The conduction band offset (CBO) is found to increase with the magnitude of biaxial strain.

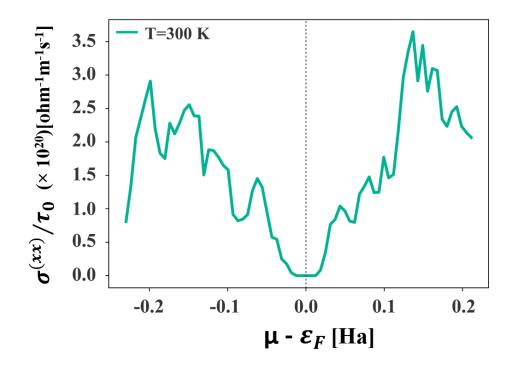


Figure S6: Calculated plot of electrical conductivity of the MoS<sub>2</sub>/BP vdW heterobilayer as a function of chemical potential.

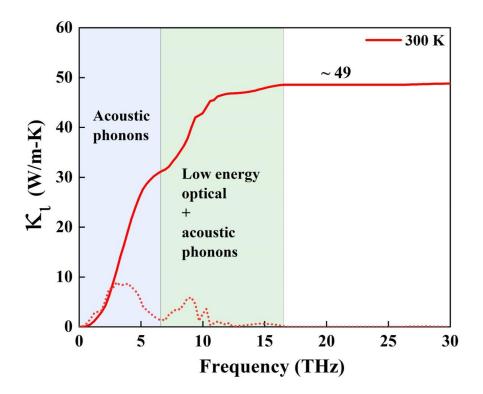


Figure S7: Cumulative lattice thermal conductivity (red solid line) and its derivative (red dash line) at 300K with contribution of low energy optical mode and acoustic mode towards the total lattice thermal conductivity.

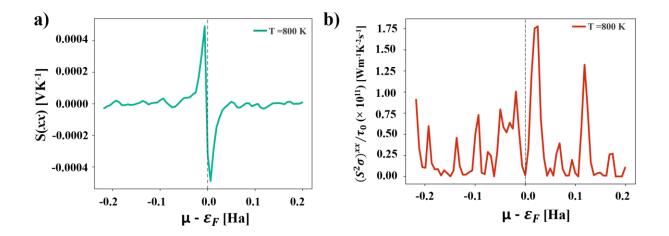


Figure S8: Calculated (a) Seebeck coefficient and (b) thermoelectric power factor at 800 K for MoS<sub>2</sub>/BP heterobilayer as a function of chemical potential

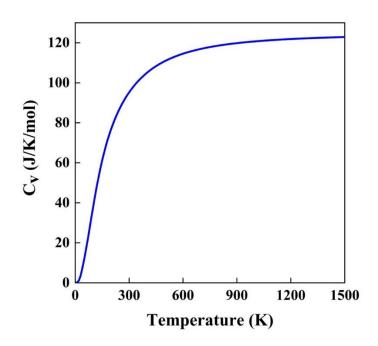


Figure S9: Calculated volumetric heat capacity as a function of temperature

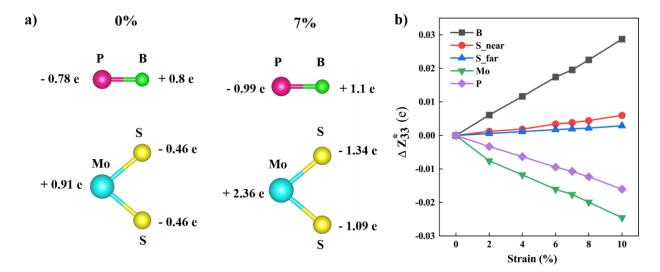


Figure S10: (a) Bader atomic charges at different % of vertical compressive strain of MoS<sub>2</sub>/BP (stacking I), (b) Variation in the change in Born effective charges on B, Mo, P and the S ions along the z-direction  $(\Delta Z^*_{33})$  relative to the pristine, unstrained hetero-bilayer with the application of vertical compressive strain. S\_near and S\_far denote S ion near to and far from the BP monolayer.

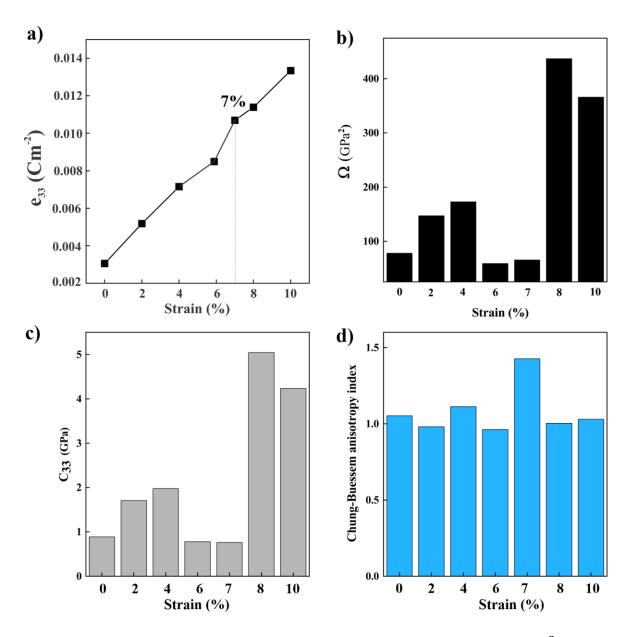


Figure S11: Variation in (a) piezoelectric stress tensor, (b)  $\Omega = (C_{11} + C_{12})C_{33} - 2C_{13}^2$ , (c) C<sub>33</sub> and (d) Chung-Buessem anisotropy index (for anisotropy in elastic stiffness) in the heterobilayer with vertical compressive strain.

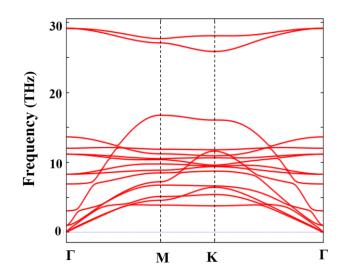


Figure S12: Phonon dispersion of 7% vertical compressive strain MoS<sub>2</sub>/BP heterobilayer.

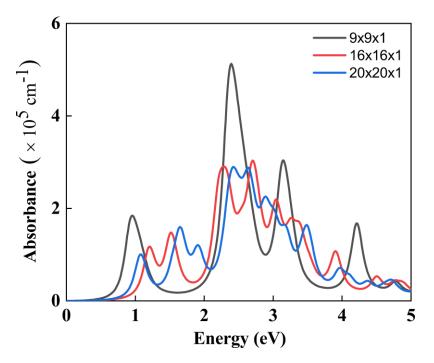


Figure S13: The calculated absorption spectra of *h*-BP monolayer with different *k*-mesh sampling. A 9x9x1 k-mesh was used in an earlier work.<sup>3</sup>

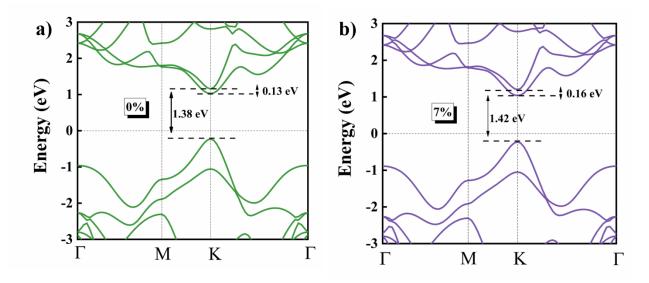


Figure S14: Electronic band dispersion (HSE06) of  $MoS_2/BP$  (a) unstrained and (b) 7 % vertical compressive strain. The bands arising from the individual monolayers are shown in Fig. 2(c). The conduction band offset (CBO) changes marginally with the application of vertical compressive strain.

Table-S1 Calculated effective mass (m*), deformation potential constant E <sub>i</sub> (eV) and carrier										
mobility $\mu$ (cm <sup>2</sup> V <sup>-1</sup> s <sup>-1</sup> ) for electrons and holes along high symmetric directions of MoS <sub>2</sub> and										
BP monolayers at 300 K										
			1* / 1		(*103)					

Monolayer	Direction	Carrier type	$ m^*/m_o $	<i>E</i> <sub><i>i</i></sub>	μ (*10 <sup>3</sup> )
MoS <sub>2</sub>	$K \rightarrow \Gamma$	Electron	0.535	9.33	0.141
		Hole	0.719	4.93	0.299
	$K \rightarrow M$	Electron	0.476	9.33	0.158
		Hole	0.561	4.93	0.383
BP	$K \rightarrow \Gamma$	Electron	0.224	0.94	57.74
		Hole	0.217	2.45	9.39
	$K \rightarrow M$	Electron	0.373	0.96	34.31
		Hole	0.313	2.62	6.2

Table-S2 Calculated optimized geometrical parameters of the hetero-bilayer: equilibrium distance, binding energy (DFT-D3)									
MoS <sub>2</sub> /BP	<b>d</b> <sub>0</sub> (Å)	Binding energy (meV/Å <sup>2</sup> )							
II	3.2	-22.3							
III	3.6	-17.48							
IV	3.57	-18.37							

	Table-S3 Calculated relaxed ion (Electronic + Ionic) piezoelectric tensor $e_{ij}$ (unit: C/m²)and total elastic modulus $C_{ij}$ (unit: GPa) of MoS2/BP heterobilayer										
	е	ij		C <sub>ij</sub>							
	1	2	3		1	2	3				
1	-	-	-	1	69.17	18.5	-0.06				
2	0.0251	-0.0256	-0.0006	2	18.5	69	0.11				
3	0.001	0.001	0.003	3	-0.06	0.11	0.88				

	Stacking	Atoms	Bor	n effective char	ges
			XX	YY	ZZ
Pristine		Mo	-1	-1	-0.08
		S	0.5	0.5	0.001
		В	1.58	1.59	-0.02
		Р	-1.58	-1.59	0.02
Heterobilayer	Ι	Mo	-0.95	-0.95	-0.12
		S	0.43	0.43	0.07
		В	1.79	1.8	0.007
		Р	-1.75	-1.77	-0.005
	II	Mo	-0.99	-0.99	-0.1
		S	0.45	0.45	0.067
		В	1.83	1.83	-0.02
		Р	-1.76	-1.75	0.007
	III	Mo	-0.91	-0.92	-0.1
		S	0.47	0.48	0.063
		В	1.77	1.77	-0.04
		Р	-1.81	-1.81	0.03
	IV	Mo	-0.9	-0.9	-0.11
		S	0.44	0.45	0.07
		В	1.7	1.71	-0.043
		Р	-1.72	-1.74	0.39

Table-S4	Born	effective	charges	on	each	ionic	species	in	pristine/unstrained
heterobila	yer								

Born effective charge (BEC) tensors,  $Z_{ij}^*$  provide microscopic insight into the piezoelectric coefficients via changes in intrinsic polarization ( $P_i$ ) in the system.  $Z_{ij}^* = \Omega_0 \frac{\partial P_i}{\partial u_j}$  (VI), where *i*, j = x, y, z direction and  $\Omega_0$  is the unit cell volume, *u* is the displacement of the atom along a particular direction.

Table-S5 Born effective of	charges on each ionic spe	ecies along z direction in			
unstrained/strained condition	l				
Heterobilayer	Atoms	Born effective charges along			
		the z direction			
		$(Z^*_{zz} \text{ or, } Z^*_{33})$			
BP/MoS <sub>2</sub>	В	0.0075			
	Р	-0.0054			
(pristine/unstrained)	Мо	-0.12			
	S	0.047			
	S	0.07			
BP/MoS <sub>2</sub>	В	0.027			
(7 % compressive strain)	Р	-0.016			
	Мо	-0.134			
	S	0.049			
	S	0.074			

Table-S6 Calculated elastic constants  $C_{11}$ ,  $C_{22}$ ,  $C_{12}$  (N/m), Young's modulus Y (N/m), shear moduli  $G_{xy}$  (N/m), Poisson's ratio (v) in 7% strained MoS<sub>2</sub>/BP calculated using AELAS code<sup>4</sup>

System	<i>C</i> <sub>11</sub>	<i>C</i> <sub>22</sub>	<i>C</i> <sub>12</sub>	$Y_x$	Y <sub>y</sub>	G <sub>xy</sub>	$v_x$	$v_y$	Status
MoS <sub>2</sub> /BP	310.98	310.98	75.86	292.47	292.47	117.56	0.24	0.24	Stable

## References:

- Zhou, Y.; Wu, D.; Zhu, Y.; Cho, Y.; He, Q.; Yang, X.; Herrera, K.; Chu, Z.; Han, Y.; Downer, M. C.; et al. Out-of-Plane Piezoelectricity and Ferroelectricity in Layered α-In2Se3 Nanoflakes. *Nano Lett.* 2017, 17 (9), 5508–5513. https://doi.org/10.1021/acs.nanolett.7b02198.
- (2) Yin, H.; Gao, J.; Zheng, G.-P.; Wang, Y.; Ma, Y. Giant Piezoelectric Effects in Monolayer Group-V Binary Compounds with Honeycomb Phases: A First-Principles Prediction. *J. Phys. Chem. C* **2017**, *121* (45), 25576–25584. https://doi.org/10.1021/acs.jpcc.7b08822.
- (3) Mohanta, M. K.; Rawat, A.; Dimple; Jena, N.; Ahammed, R.; De Sarkar, A. Superhigh Out-of-Plane Piezoelectricity, Low Thermal Conductivity and Photocatalytic Abilities in Ultrathin 2D van Der Waals Heterostructures of Boron Monophosphide and Gallium Nitride. *Nanoscale* 2019, 11 (45), 21880–21890. https://doi.org/10.1039/C9NR07586K.
- (4) Zhang, S. H.; Zhang, R. F. AELAS: Automatic ELAStic Property Derivations via High-Throughput First-Principles Computation. *Computer Physics Communications* **2017**, *220*, 403–416. https://doi.org/10.1016/j.cpc.2017.07.020.